

## 6.2 6.3 6.6 6.7 6.8 6.9 计算题部分

6-2  
NMOS管的阈值电压大于0, 电流与 $I_D$ 值随 $V_{GS}$ 增大而增大  
PMOS管的阈值电压小于0, 即 $I_D$ 值随 $V_{GS}$ 的减小而增大  
PMOS管: 阈值电压小于0,  $I_D$ 随 $V_{GS}$ 的减小而增大  
PMOS管: 阈值电压大于0,  $I_D$ 随 $V_{GS}$ 的减小而增大

6-3  
 $I_D$  - 漏极电流  $V_{GS}$  - 栅极电压  $V_{DS}$  - 漏极电压  
 $g_m$  - 跨导  $\frac{I_D}{V_{GS} - V_T}$  - 增益  
 $g_m = \frac{\partial I_D}{\partial V_{GS}} = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T) = \frac{2 I_D}{V_{GS} - V_T}$   
 $V_{GS} = \frac{I_D}{g_m} = \frac{I_D}{\mu_n C_{ox} \frac{W}{L} (V_{GS} - V_T)} = \frac{1}{\frac{2 I_D}{V_{GS} - V_T}}$

6-6  
 $I_{D1} = \frac{\mu_n C_{ox}}{2} \frac{W_1}{L_1} (V_{GS1} - V_{TN})^2 = 840 \mu A$   
 $I_{D2} = 10 \mu A = 10^{-5} A$   
 $\frac{I_{D1}}{I_{D2}} = \frac{W_1}{W_2} \Rightarrow \frac{840}{10} = \frac{W_1}{W_2} \Rightarrow \frac{W_1}{W_2} = 84$   
 $\frac{W_1}{L_1} = 119$   
 $\mu_n C_{ox} = 2.38 \mu A/V^2$

6.7  
 $I_{ref} = \frac{\mu_n C_{ox}}{2} \frac{W_1}{L_1} (V_{GS1} - V_{TN})^2 = \frac{\mu_n C_{ox}}{2} \frac{W_2}{L_2} (V_{GS2} - V_{TN})^2 = 0.25 mA$   
 $V_{GS1} = V_{GS2} = 1.85 V$   
 $I_0 = \frac{\mu_n C_{ox}}{2} \frac{W_2}{L_2} (V_{GS2} - V_{TN})^2 = 0.1 mA$   
 $\frac{W_1}{L_1} : \frac{W_2}{L_2} = I_{ref} : I_0$   
 $\frac{W_1}{L_1} = 17.5$   
 $I_{ref} = \frac{\mu_n C_{ox}}{2} \frac{W_3}{L_3} (V_{GS3} - V_{TN})^2 = 0.25 mA \Rightarrow \frac{W_3}{L_3} = 2.7$

6.8  
 $I_{ref} = K_{n4} (V_{GS4} - V_{TN4})^2 = 0.1 mA$   
 $K_{n1} = K_{n2} = K_{n3} = K_{n4}$ ,  $M_1, M_2$  构成电流镜  
 $I_0 = I_{ref} = 0.1 mA$   
 $V_{GS3} = V_{GS2}$   
 $I_0 = K_{n2} (V_{GS2} - V_{TN2})^2$   
 $V_{GS2} = 2 V$   
 $V_{GS1} = 1 V$   
 $I_0 = K_{n1} (V_{GS1} - V_{TN1})^2$   
 $V_{GS1} = 1.7 V$   
 $V_{DS1} = 3.3 V$

6.9  
 $V_{GS, NMOS} = V_{GS, PMOS} \leq 1.5 V$   
取等时,  
 $1.5 = V_{TN} + \sqrt{\frac{I_{ref}}{\mu_n C_{ox} \frac{W_1}{L_1}}}$   
 $\frac{W_1}{L_1} = 1.6$

$I_2 = 10 \mu A$   
 $\frac{W_1}{L_1} : \frac{W_2}{L_2} = I_1 : I_2 \Rightarrow \frac{W_2}{L_2} = 1.6$   
 $I_3 = 40 \mu A$   
 $\frac{W_1}{L_1} : \frac{W_3}{L_3} = I_1 : I_3 \Rightarrow \frac{W_3}{L_3} = 6.4$   
同理,  $\frac{W_4}{L_4} = 3.2$   
 $I_{D5} = 10 \mu A \Rightarrow \frac{W_5}{L_5} = 3.2$   
 $I_{D6} = 20 \mu A \Rightarrow \frac{W_6}{L_6} = 6.4$

## 6.4

```

**** mosfets

.title NMOS_DC

VVDS net2 0 DC 1.8V
VVGs net1 0 DC 0.75V
MNMO net2 net1 0 0 nl8 W=5u L=180n m=1

.op
.dc VVDS 0 1.8 0.1

.probe i(MNMO)

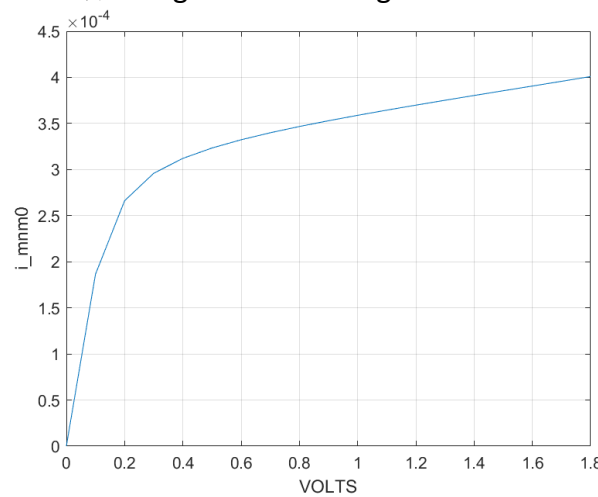
.temp 27
.option post accurate probe
.lib '..\models\ms018.lib' tt

.end

```

Parameter	Value
subckt	0:mnmo
element	0:nl8
model	0:nl8
region	Saturati
id	400.7171u
ibs	-1.581e-19
ibd	-198.5012n
vgs	750.0000m
vds	1.8000
vbs	0.
vth	463.8470m
vdsat	206.7342m
vod	286.1530m
beta	10.8271m
gam eff	771.0519m
gm	2.0424m
gds	51.8797u
gmb	475.4409u
cdtot	4.5399f
cgtot	9.1868f
cstot	11.7318f
cbtot	9.0992f
cgs	6.5727f
cgd	1.7714f

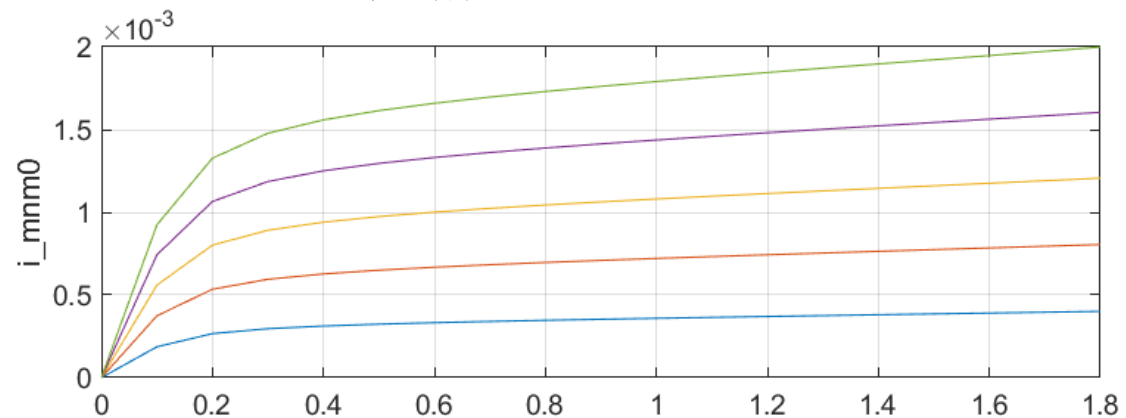
可以看出:  $gm=2.0424m$   $gds=51.8797u$   $cgs=6.5727f$   $cgd=1.7714f$



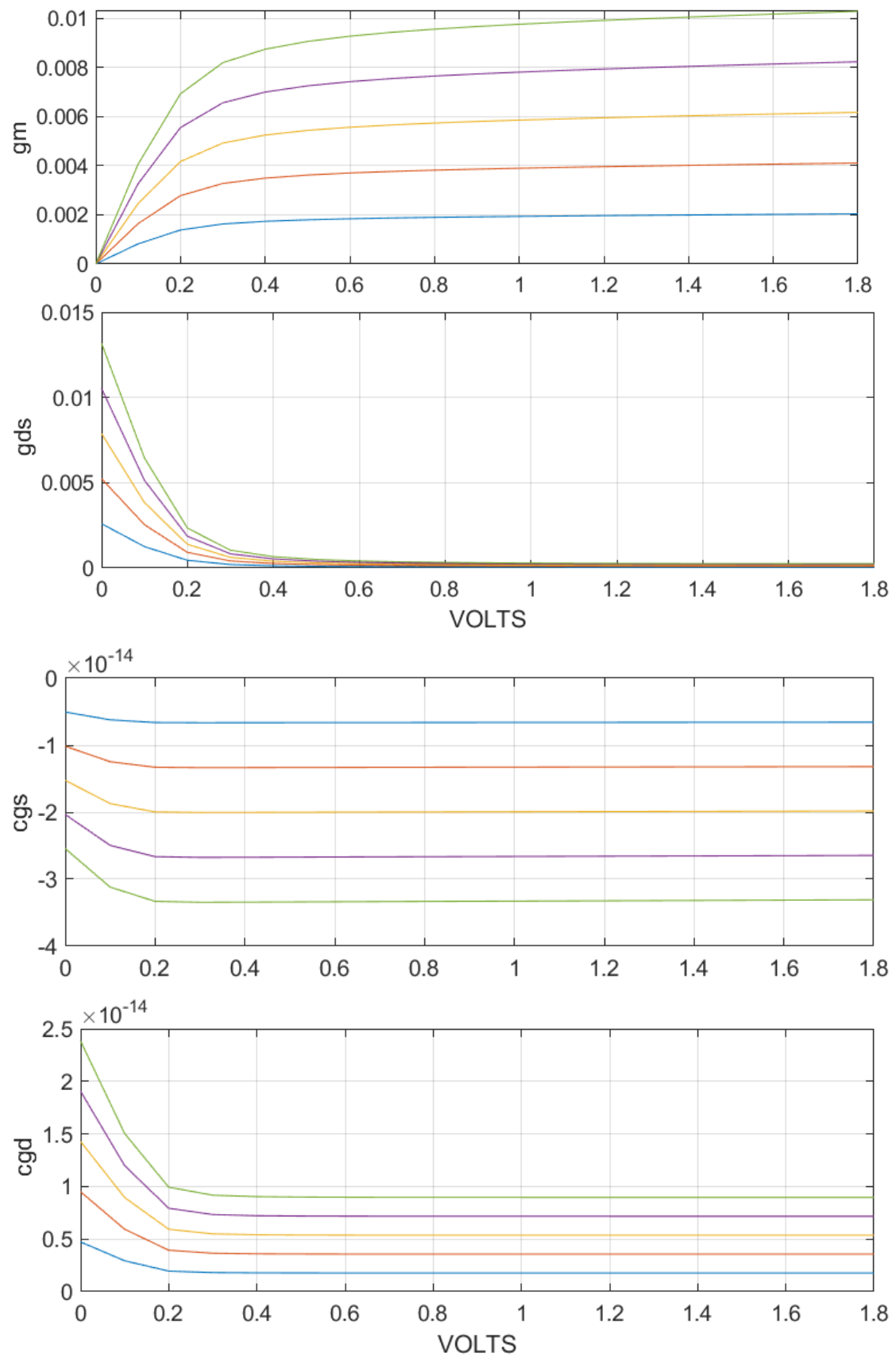
输出特性曲线如右图所示。

## 6.5

选取不同宽长比时, mos 管的特征曲线:

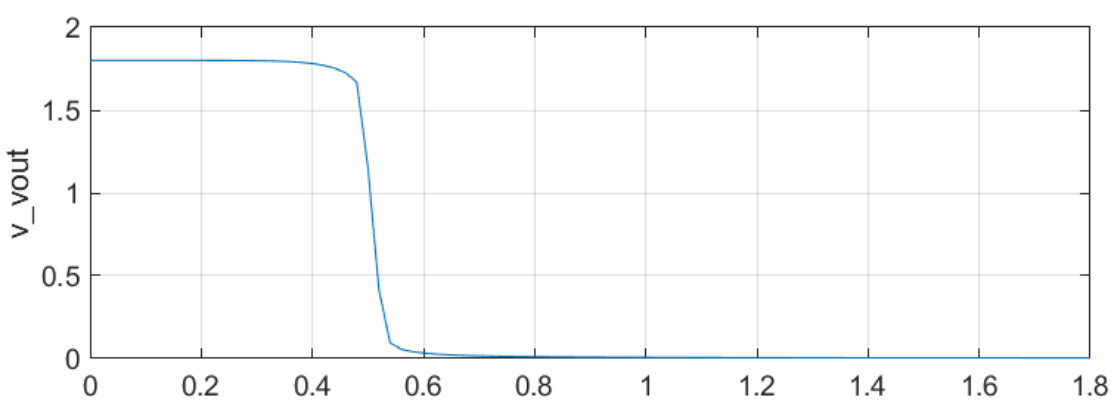


对于  $i_d$ 、 $gm$ 、 $gds$ 、 $cgs$ 、 $cgd$  的影响:



在栅极电压一定时，栅极宽长比变化，导致  $i$  发生变化，则导致电压与电流的比值发生改变，过会使电导、电容等发生改变。

6.11 仿真结果不太对，但是也不知道错在哪里了/(T o T)/~~

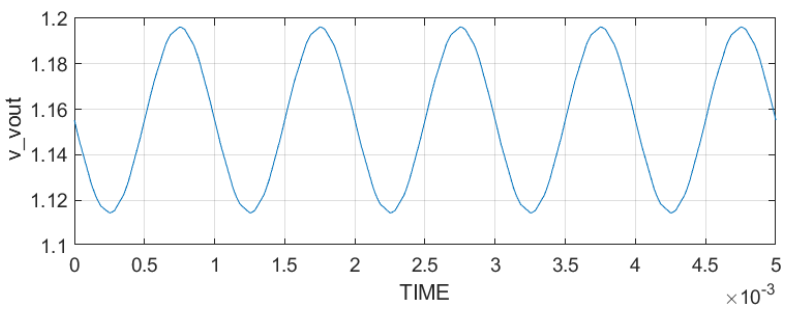
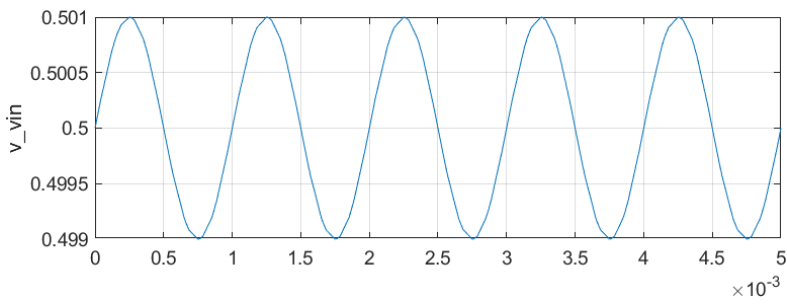


有图可得：0.55V 可作为合适的直流偏置电流

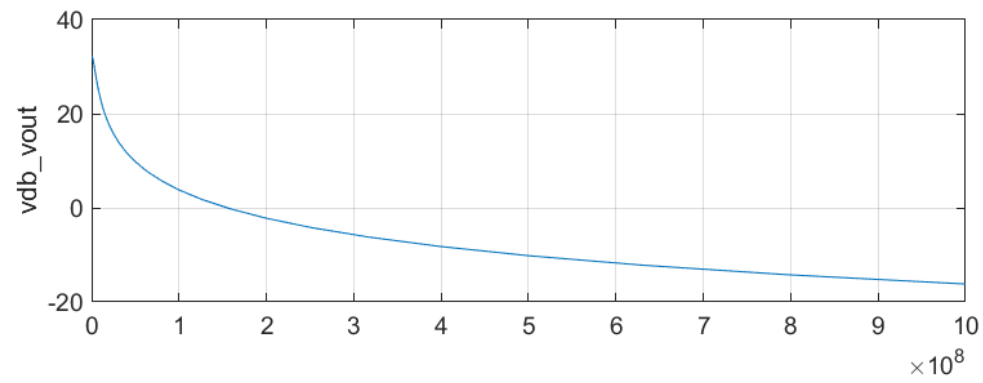
subckt	x1	x1
element	1:mm1	1:mm2
model	0:n18	0:pl8
region	Saturati	Saturati
id	63.4178u	-63.4185u
ibs	-4.563e-20	9.223e-20
ibd	-733.1166p	26.0073a
vgs	500.0000m	-600.0000m
vds	1.1553	-644.7331m
vbs	0.	0.
vth	472.5030m	-425.2597m
vdsat	79.7140m	-174.1581m
vod	27.4970m	-174.7403m
beta	22.3093m	4.2527m
gam_eff	772.6355m	577.4186m
gm	1.0583m	635.4975u
gds	23.6345u	2.2378u
gmb	258.5964u	203.9426u
cdtot	9.7757f	74.2698f
cgtot	15.4840f	411.4351f
cstot	19.5483f	483.1730f
cbtot	18.7000f	240.2132f
cgs	9.6150f	352.8751f
cgd	3.6066f	25.3152f

gm、gds、cgs、cgd 可由右图给出

瞬态仿真：



交流仿真：



6.12 11 题出问题，导致这题算不对

6.12 取  $V_{in} = 0.55$

(1) 由低频交流小信号模型知

$$A_0 = \frac{g_{m1}}{g_{ds1} + g_{ds2}}$$

(2) 高频交流小信号要加上电容

电容以  $C_L$  为主

$$A(s) = \frac{A_0}{1 + sRC} \quad R = \frac{1}{g_{ds1} + g_{ds2}}$$